

CMOS VCOs for Frequency Synthesis in Wireless Biotelemetry Rafael J. Betancourt Zamora and Thomas H. Lee

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Phase Noise Theory

Oscillators are Time-Variant Systems Hajimiri Phase Noise Model Differential Buffer Topology Clamned load Symmetric load Phase Noise in 1/f² region is due to device 1/f noise. BR It is commonly assumed that the 1/t³ corner of phase. noise is the same as the 1/f corner of the device noise spectrum. This is NOT the case. $L(\Delta \omega)$ OPAMP $f_{1/f^3} = f_{1/f} \cdot \frac{\Gamma_{dc}^2}{\Gamma_{rme}^2}$ dBa/U Vbias Current impulse injected at the Current impulse injected at zero. peak changes the amplitude and crossing changes the phase and has · Use buffers with replica-feedback biasing has no effect on the phase. minimal effect on the amplitude. Phase Noise in 1/f² region is due · NMOS differential pairs with linear PMOS loads. Vbias to device thermal noise V_{ctl} changes the bias I_{dd} of the buffers. Vhias $L(\Delta \omega) = 10 \cdot \log \left\{ \frac{\Gamma_{rms}^2}{a^2} \cdot \frac{l_n^2 / \Delta f}{2 \cdot \Delta \omega^2} \right\}$ · Replica bias ensures loads are mostly in their linear region by forcing $h_{\phi}(t, \tau) = \frac{\Gamma(\omega_0 \tau)}{q_{max}} u(t - \tau)$ the maximum single-ended swing $V_s = V_{dd} - V_{ctl}$ A im · Sweep width of cross-coupling · Frequency is controlled by changing the bias of the buffers and hence devices with fixed total width the delay through each cell. Impulse Sensitivity Function Γ(x) is periodic. (W1+W2=W3=6um) of the loads Power dissipation is determined by frequency and phase noise required · qmax is the maximum charge displacement in the tank. · Maximum symmetry for $W_1 = W_2 = 0.5W_3$ Impulse Sensitivity Function for Ring Oscillators Power Dissipation of Differential Ring Oscillator Calculation of Γ_{rms} and Γ_{dc} for Ring Oscillators $P \simeq 2N^2 C_I V_{JJ} V_J f$ Wn=3um Wn=6um Wn=12um $\Gamma(x)$ N is number of stages C_l is total load capacitance at each $\phi(t) = \frac{1}{q_{max}} \left[\frac{c_o}{2} \int_{-\infty}^{t} i(\tau) d\tau + \sum_{n=0}^{\infty} c_n \int_{-\infty}^{t} i_n(\tau) \cos(n\omega\tau) d\tau \right]$ huffer V_s is maximum single-ended swing S is the maximum slope V_{dd} is 3.3V Γ(x) is calculated from the output waveform. of the normalized output waveform • Γ(x) is expressed as a Fourier series and used to determine the phase noise resulting from noise sources. N is the number of stages · High sensitivity to noise at the transitions of the output waveform requency MHz Upconversion of Device 1/f Noise Phase Noise of Differential Ring Oscillator (1/f² region) Phase Noise vs. Power Dissipation 100 Offset Frequency, Hz $L\{\Delta f\} \ge \frac{18kTV_{dd}}{r^2 n} \cdot \left(\frac{2.5}{E_r L_{-re}} + 1\right) \cdot \left(\frac{f_o}{\Delta f}\right)^2 \cdot N$ (Lower bound) Wn=3um Wn=6um Oscillator 1/f³ corner Wn=12um (a) Clamped Load 137KHz N is number of Wn=3um (b) Symmetric Load 36KHz stages 100KHz, Wn=6um (c) Cross-coupled Load 6.5KHz Minimum length Wn=12un short-channel differential pair 00KHz, ര devices Assumed f_{1/f} = 3MHz L_{eff} = 0.5μm • $F_{c} = 5.6 \times 10^{6} \text{V/m}$ Š 0 similarly sized noise sources. 21

- · Phase noise close to the carrier results from the folding of device noise centered at integer multiples of the carrier frequency.
- Upconversion of device 1/f noise occurs through Γ_{dc}, the DC value of the ISF.
- Γ_{de} is governed by the symmetry properties of the waveform.



Voltage-controlled Oscillator Design



Selected Wn=6µm for 200MHz at 2.1dBm (1.6mW), -90dBc/Hz @ 100KHz

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